

Magnetic Properties of a Thin Layer of Oriented Single Domain Magnetic Nanoparticles

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Magnetic ions—Fe, Co, and Ni—have been implanted into the near-surface region of single crystals of Al_2O_3 and yttria stabilized zirconia (YSZ). With thermal processing, the implanted species precipitate to form predominantly single-domain, single-crystal ferromagnetic nanoparticles that crystallographically align with the host substrate, thereby forming a magnetically anisotropic nanocomposite surface. In the case of Fe, precipitates were formed in YSZ by implantation of Fe^+ at an energy of 140 keV and a dose of 8×10^{16} ions/cm², followed by annealing in a reducing atmosphere. Similarly for Co, precipitates were formed in Al_2O_3 by implantation of Co^+ at an energy of 140 keV and a dose of 8×10^{16} ions/cm², followed by annealing in a reducing atmosphere. To form Ni precipitates, Ni^+ was implanted in Al_2O_3 at an energy of 750 keV and doses of 5×10^{16} , 1×10^{17} , and 2×10^{17} ions/cm², followed by annealing in a reducing atmosphere. Typical dimensions for the particle size and layer thickness are 10 nm and 80 nm, respectively, allowing for nearly 10% volume filling in the layer, as measured by RBS/channeling, transmission electron microscopy, and x-ray diffraction. Studies on these ferromagnetic particle layers were conducted in the temperature range of 5 to 300 K and applied fields of 10 kG using a superconducting quantum interference device (SQUID)-based magnetometer. An analysis of the magnetic properties including retentivity, coercivity, and saturation moment will be presented as well as the effects of magnetocrystalline and shape anisotropy. Additionally, the particle/host orientation dependence will be treated by comparisons with Ni precipitates in an amorphous substrate of SiO_2 .

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